

Toward multiscale modeling of thin-film growth processes using SLKMC – ERRATUM

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The paper by Acharya and Rahman¹ was inadvertently published in Volume 33, Issue 6 of *Journal of Materials Research*. The article is part of the *Journal of Materials Research* Focus Issue on Advanced Atomistic Algorithms in Materials Science and is referenced as such in the introduction to that issue.²

The publishers apologize for the error.

REFERENCES

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